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constituent <sup>as</sup> with the ultrafine ceramic oxide powder in water or  
an organic solvent; dispersing by mixing <sup>with the ceramic sol solution</sup> the suspension in which  
the ultrafine ceramic oxide powder is dispersed ~~with the ceramic~~  
~~sol solution~~; forming a piezoelectric/electrostrictive film  
element by submerging a substrate into the suspension, <sup>a</sup> which the  
ultrafine ceramic oxide powder and the ceramic sol solution are  
mixed and then ~~by~~ performing electrophoretic deposition; and  
thermally treating the piezoelectric/electrostrictive film  
element at 100-600°C, so that the solvent is removed by the  
thermal treatment and ~~the~~ bonding among the ultrafine ceramic  
oxide powder particles is induced, while the ceramic sol acts as  
a reaction medium on the surfaces of the ceramic oxide  
particles.

#### BRIEF DESCRIPTION OF THE DRAWINGS

Figure 1 is a flow diagram <sup>for</sup> producing method <sup>of</sup> ultrafine ceramic oxide powder used in the present invention.

Figure 2 is a flow diagram of <sup>a</sup> forming process <sup>for forming</sup> of piezoelectric/electrostrictive film element using the conventional electrophoretic deposition.

Figure 3 is a flow diagram of a method for forming a piezoelectric/electrostrictive film element using the electrophoretic deposition at low temperature according to the present invention.

#### DETAIL DESCRIPTION

The present invention will be explained in detail.

First, a method for producing <sup>a</sup> ultrafine ceramic oxide powder used as a raw material in <sup>a</sup> piezoelectric/electrostrictive film element, <sup>producing</sup> according to the present invention as in

<sup>the</sup>  
a flow diagram of Figure 1 will be explained.

5 A <sup>n</sup>ultrafine ceramic oxide powder <sup>manufacturing</sup> ~~producing~~ method of the ✓  
present invention comprises the steps of: sufficiently  
dissolving or uniformly dispersing the raw material of  
constituent ceramic elements in <sup>a</sup> solvent or dispersant to make a  
solution or a dispersion mixture containing the constituent  
ceramic elements; adding, into the solution or the dispersion  
mixture containing the constituent ceramic elements, citric acid  
in no less than the required amount to give rise to <sup>an</sup>  
oxidative-reductive combustion reaction with an anion of the  
ceramic constituent ceramic element so as to make a mixed  
solution; and thermally treating the mixed liquid at 100-500°C.  
But it may additionally further comprises a step of conducting  
additional thermal treatment at 700-900°C to increase  
crystallinity.

10 As for the raw material containing the constituent ceramic  
elements, use is made of ~~from among~~ <sup>or</sup> oxide, carbonate, nitrate ✓  
etc. of constituent ceramic element, its salt with organics or  
inorganics, or <sup>a</sup> constituent ceramic elements ~~complex~~. ✓

20 As for the constituent ceramic element, it is preferable to  
use a piezoelectric/electrostrictive ceramic element comprising  
lead (Pb) and titanium (Ti) as basic constituent elements.

25 Especially as <sup>to</sup> ~~for~~ the constituent ceramic element, it is ✓  
preferable to use that composed of elements including lead (Pb),  
zirconium (Zr) and titanium (Ti), or lead (Pb), zirconium (Zr),  
titanium (Ti) / lead (Pb), magnesium (Mg), niobium (Nb).

As for the solvent, or the dispersant to dissolve or  
disperse the raw material of <sup>to</sup> constituent ceramic elements, one ✓  
^

or more are selected ~~to use~~ from among water and organic solvents that can dissolve or disperse the raw material containing the constituent ceramic elements. As for the organic solvents, mainly acetic acid, dimethyl formamide, methoxyethanol, alcohols, <sup>or</sup> glycols ~~etc.~~ are used.

As for the combustion aid, citric acid is used, which is an organic compound that can give rise to combustion reaction. In the conventional method, ~~the~~ citric acid has been used, not as a combustion aid, but <sup>as</sup> a complexing agent in order to give reaction uniformity, and <sup>it</sup> has been used in process <sup>es</sup> such as <sup>the</sup> Pechini process, where <sup>a</sup> speed-controlled combustion reaction can be induced using citric acid's flammability and complex formation effect.

A mixture is made by adding citric acid into a solution or a dispersed mixture where constituent ceramic elements are dissolved or dispersed. The quantity of the citric acid added shall not be less than the necessary amount to give rise to oxidative-reductive combustion reaction with the anion of the constituent ceramic element. Reaction speed can be controlled by the quantity of citric acid added.

The mixture made by the addition of the citric acid is thermally treated at 100-500°C. Though the crystallinity of the ceramic phase increases <sup>with</sup> ~~as~~ the temperature for the thermal treatment, the citric acid combustion reaction may start enough if <sup>the</sup> ~~only~~ temperature for the thermal treatment is over 100°C. ~~And~~ Although <sup>the</sup> reaction can arise even if the temperature for the thermal treatment is above 500°C, thermally treating above that temperature is meaningless when comparing <sup>ed</sup> with the conventional method.